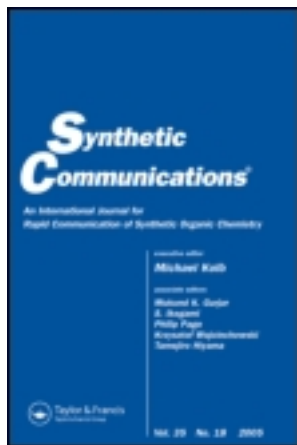


This article was downloaded by: [University of Connecticut]

On: 19 May 2013, At: 21:40

Publisher: Taylor & Francis

Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-41 Mortimer Street, London W1T 3JH, UK



Synthetic Communications: An International Journal for Rapid Communication of Synthetic Organic Chemistry

Publication details, including instructions for authors and subscription information:

<http://www.tandfonline.com/loi/lcyc20>

SILICA CHLORIDE/ NaNO_2 AS A NOVEL HETEROGENEOUS SYSTEM FOR THE NITROSATION OF SECONDARY AMINES UNDER MILD CONDITIONS

Mohammad Ali Zolfigol^a, Farhad Shirini^b & Arash Ghorbani Choghamarani^a

^a Chemistry Department, College of Science, Bu-Ali Sina University, Post Box No. 4135, Hamadan, 65174, Iran

^b Chemistry Department, College of Science, Gilan University, Rasht, Iran

Published online: 17 Oct 2011.

To cite this article: Mohammad Ali Zolfigol, Farhad Shirini & Arash Ghorbani Choghamarani (2002): SILICA CHLORIDE/ NaNO_2 AS A NOVEL HETEROGENEOUS SYSTEM FOR THE NITROSATION OF SECONDARY AMINES UNDER MILD CONDITIONS, Synthetic Communications: An International Journal for Rapid Communication of Synthetic Organic Chemistry, 32:12, 1809-1813

To link to this article: <http://dx.doi.org/10.1081/SCC-120004060>

PLEASE SCROLL DOWN FOR ARTICLE

Full terms and conditions of use: <http://www.tandfonline.com/page/terms-and-conditions>

This article may be used for research, teaching, and private study purposes. Any substantial or systematic reproduction, redistribution, reselling, loan, sub-licensing, systematic supply, or distribution in any form to anyone is expressly forbidden.

The publisher does not give any warranty express or implied or make any representation that the contents will be complete or accurate or up to date. The accuracy of any instructions, formulae, and drug doses should be independently verified with primary sources. The publisher shall not be liable for any loss, actions, claims, proceedings, demand, or costs or damages whatsoever or howsoever caused arising directly or indirectly in connection with or arising out of the use of this material.



SYNTHETIC COMMUNICATIONS, 32(12), 1809–1813 (2002)

SILICA CHLORIDE/ NaNO_2 AS A NOVEL HETEROGENEOUS SYSTEM FOR THE NITROSATION OF SECONDARY AMINES UNDER MILD CONDITIONS

Mohammad Ali Zolfigol,^{1,*} Farhad Shirini,²
and Arash Ghorbani Choghamarani¹

¹Chemistry Department, College of Science,
Bu-Ali Sina University, Hamadan, Zip Code 65174,
Post Box No. 4135, Iran

²Chemistry Department, College of Science,
Gilan University, Rasht, Iran

ABSTRACT

Secondary amines can be readily converted to their corresponding nitroso derivatives with a combination of silica chloride (**I**), wet SiO_2 and sodium nitrite in dichloromethane at room temperature with moderate to excellent yields.

N-Nitrosation chemistry of amines is an important and well-established reaction in organic synthesis.^[1] The most general reagent is nitrous acid, generated from sodium nitrite and mineral acid in water or in mixed alcohol–water solvents.^[2] Other nitrosating agents, such as Fremy's salt,^[3] *bis*(triphenylphosphine)nitrogen(1 +)nitrite,^[4] *N*-haloamides

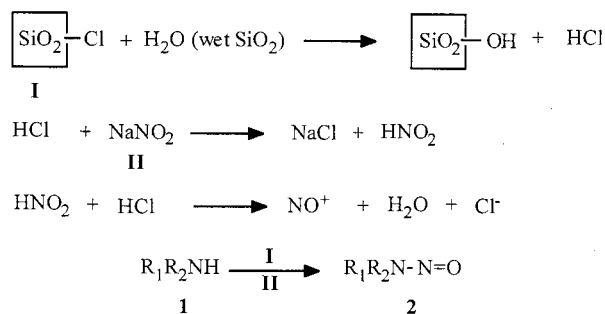
*Corresponding author. Fax: (+98) 811 8272404; E-mail: Zolfi@basu.ac.ir



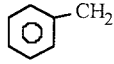


1810 ZOLFIGOL, SHIRINI, AND GHORBANI CHOGHAMARANI

and sodium nitrite under phase-transfer conditions,^[5] oxyhyponitrite,^[6] dinitrogen tetroxide,^[7] solid acids (i.e. oxalic acid dihydrate,^[8] inorganic acidic salts^[9] and hydrolyzable chloride salts^[10]) and sodium nitrite have also been used.

There is intense current research and general interest in heterogeneous systems because of the perceived opportunities such systems present for basic research and because of the unquestioned importance such systems have in industry and in developing technologies.^[12,13] In continuation of our studies on the application of inorganic acidic salts^[11] we found that the silica chloride^[14,15] (**I**) is an excellent source for generation of HCl. It is interesting to note that the addition of wet SiO₂ to the reaction mixture containing silica chloride could generate HCl in situ. Therefore, we were interested in using this reagent (**I**) for the nitrosation of secondary amines via in situ generation of HNO₂ and NO⁺ respectively when used in conjunction with NaNO₂, wet SiO₂ in organic solvent (Scheme 1). We wish to report a simple



1 or 2	R ₁ = R ₂	1 or 2	R ₁ = R ₂
a	Me	f	-(CH ₂) ₂ -O-(CH ₂) ₂ -
b	Et	g	-(CH ₂) ₅ -
c	<i>iso</i> -Pr	h	
d		i	

Scheme 1.

SILICA CHLORIDE/ NaNO_2

1811

Table 1. Nitrosation of Secondary Amines (**1**) to Their Corresponding Nitrosoamines (**2**) with a Combination of Silica Chloride (**I**), NaNO_2 (**II**), and Wet SiO_2 (50% w/w) in Dichloromethane at Room Temperature

Entry	Substrate	Product ^a	(Reagent/Substrate) ^b		Time (h)	Yield ^c (%)
			I (g)	II (mmol)		
1	1a	2a	0.3	1.5	0.75	100 ^d
2	1b	2b	0.3	1.5	0.75	90
3	1c	2c	0.3	1.5	1	95
4	1d	2d	0.3	1.5	1.5	98
5	1e	2e	0.3	1.5	0.75	95
6	1f	2f	0.3	1.5	0.75	95
7	1g	2g	0.3	1.5	1.5	98
8	1h	2j	0.3	1.5	1.5	92

^aAll of the isolated products are known and their spectra and physical data have been reported in the literature; ^bWet SiO_2 : substrate (0.2 g : 1 mmol); ^cIsolated yields; ^dConversion.

method for the effective nitrosation of secondary amines under mild and heterogeneous conditions.

A range of secondary amines (**1**) was subjected to the nitrosation reaction in the presence of silica chloride (**I**), NaNO_2 (**II**) and wet SiO_2 (50% w/w) in dichloromethane (Scheme 1). The nitrosation reactions were performed under mild and completely heterogeneous conditions at room temperature and proceeded in moderate to excellent yields (Table 1).

The nitrosation reaction did not occur in the absence of wet SiO_2 . This observation suggests that the water molecule is essential for such processes. The presence of wet SiO_2 thus provides an effective heterogeneous surface area for in situ generation of $\text{NOCl}^{[10]}$ (Scheme 1). It also eases the reaction work-up.

In conclusion, the cheapness and the availability of the reagents, easy and clean work-up, make this method attractive for large-scale operations.

EXPERIMENTAL SECTION

General

Chemicals were purchased from Fluka, Merck and Aldrich chemical companies. Yields refer to isolated pure products. The nitrosation products

**1812 ZOLFIGOL, SHIRINI, AND GHORBANI CHOGHAMARANI**

were characterized by comparison of their spectral (IR, $^1\text{H-NMR}$, $^{13}\text{C-NMR}$), TLC and physical data with the authentic samples. Silica chloride was synthesized according to the reported procedure.^[15]

General Procedure for *N*-Nitrosation of Secondary Amines

A suspension of sodium nitrite, silica chloride (The molar ratio of silica chloride and sodium nitrite to the substrate **1** was optimized Table), amine (**1**, 5 mmol), silica chloride (1.5 g), NaNO_2 (0.517 g, 7.5 mmol) and wet SiO_2 (50% w/w) in dichloromethane (10 ml) was vigorously stirred magnetically at room temperature. The progress of the reaction was followed by TLC. The reaction mixture was filtered after completion of the reaction. The residue was washed with CH_2Cl_2 (2×5 ml). Then anhydrous Na_2SO_4 (10 g) was added to the filtrate and filtered after 20 min. The solvent was evaporated and the *N*-nitroso compound (**2**) were obtained (Table 1). If further purification is needed, flash chromatography on silica gel [eluent: acetone/petroleum ether (10:90)] provides highly pure **2**.

REFERENCES

1. (a) Williams, D.L.H. *Supplement F2: The Chemistry of Amino, Nitroso, Nitro and Related Groups*; John Wiley and Sons Ltd.: 1996; 665–682; (b) Keefer, L.K.; Williams, D.L.H. *Methods in Nitric Oxide Research*; John Wiley and Sons Ltd.: 1996; 509–519.
2. (a) Vogels *Text Book of Practical Organic Chemistry*, 4th Ed., Longman: London and New York, 1986; (b) Sheriner, R.L.; Reynold, T.L.; Fuson, C.; Curtin, D.Y.; Morrill, T.C. *The Systematic Identification of Organic Compounds*, 6th Ed.; John Wiley and Sons, 1980; 220–223.
3. Castedo, L.; Riguera, R.; Vezquez, M.P. *J. Chem. Soc. Chem. Commun.* **1983**, 301.
4. Fanning, J.C.; Keefer, L.K.; Larry, K. *J. Chem. Soc. Chem. Commun.* **1987**, 955.
5. Nakajima, M.; Warner, J.C.; Anselme, J.P. *Tetrahedron Lett.* **1984**, 25, 2619.
6. Chang, S.K.; Hrrington, G.W.; Rothstein, M.; Shergalis, W.A.; Swern, D.; Vohra, S.K. *Cancer Res.* **1979**, 39, 3871.
7. Makhova, N.N.; Karpov, G.A.; Mikhailyuk, A.N.; Bova, A.E.; Khmel'nitskii, L.I.; Novikov, S.S. *Izv. Akad. Nauk SSSR. Ser. Khim.* **1978**, 1, 226.

SILICA CHLORIDE/ NaNO_2

1813

8. Zolfigol, M.A. *Synth. Commun.* **1999**, *29*, 905.
9. Zolfigol, M.A.; Ghaemi, E.; Madrakian, E.; Kiany-Borazjani, M. *Synth. Commun.* **2000**, *30*, 2057.
10. Zolfigol, M.A.; Shirini, F.; Ghorbani Choghamarani, A.; Taqian-nasab, A.; Keypour, H.; Salehzadeh, S. *J. Chem. Research (S)* **2000**, 420.
11. (a) Zolfigol, M.A.; Kiany-Borazjani, M.; Sadeghi, M.M.; Memarian, H.R.; Mohammadpoor-Baltork, I. *Synth. Commun.* **2000**, *30*, 2945; (b) Zolfigol, M.A.; Kiany-Borazjani, M.; Sadeghi, M.M.; Memarian, H.R.; Mohammadpoor-Baltork, I. *J. Chem. Research (S)* **2000**, 197; (c) Zolfigol, M.A.; Nematollahi, D.; Mallakpour, S.E. *Synth. Commun.* **1999**, *29*, 2277; (d) Zolfigol, M.A. *Synth. Commun.* **2000**, *30*, 1593; (e) Zolfigol, M.A.; Kiany-Borazjani, M.; Mallakpour, S.E.; Nassr-Isfahani, H. *Synth. Commun.* **2000**, *30*, 2573; (f) Zolfigol, M.A.; Madrakian, E.; Ghaemi, E. *Indian J. Chem.* **2000**, *39B*, 308; (g) Zolfigol, M.A.; Kiany-Borazjani, M.; Sadeghi, M.M.; Mohammadpoor-Baltork, I.; Memarian, H.R. *Synth. Commun.* **2000**, *30*, 3919.
12. Riego, J.M.; Sedin, Z.; Zaldivar, J.M.; Marziano, N.C.; Tortato, C. *Tetrahedron lett.* **1996**, *37*, 513.
13. Turro, N.J. *Tetrahedron* **1987**, *43*, 1589.
14. Mohanazadeh, F.; Momeni, A.R.; Rangbar, Y. *Tetrahedron lett.* **1994**, *33*, 6127.
15. Firouzabadi, H.; Iranpoor, N.; Karimi, B.; Hazarkhani, H. *Synlett* **2000**, 263.

Received in the UK March 27, 2001